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Abstract. In this study, we investigated inverted hybrid bulk-heterojunction solar cells with the following configuration: fluorine-doped tin oxide (FTO) |TiO₂/RGO|P3HT:PC₆₁BM|V₂O₅ or PEDOT:PSS|Ag. The TiO₂/GO dispersions were prepared by sol-gel method, employing titanium isopropoxide and graphene oxide (GO) as starting materials. The GO concentration was varied from 0.1 to 4.0 wt%. The corresponding dispersions were spin-coated onto FTO substrates and a thermal treatment was performed to remove organic materials and to reduce GO to reduced graphene oxide (RGO). The TiO₂/RGO films were characterized by x-ray diffraction, Raman spectroscopy, and microscopy techniques. Atomic force microscopy (AFM) images showed that the addition of RGO significantly changes the morphology of the TiO₂ films, with loss of uniformity and increase in surface roughness. Independent of the use of V₂O₅ or PEDOT: PSS films as the hole transport layer, the incorporation of 2.0 wt% of RGO into TiO₂ films was the optimal concentration for the best organic photovoltaic performance. The solar cells based on TiO₂/RGO (2.0 wt%) electrode exhibited a ~22.3% and ~28.9% short circuit current density (J_{sc}) and a power conversion efficiency enhancement, respectively, if compared with the devices based on pure TiO₂ films. Kelvin probe force microscopy images suggest that the incorporation of RGO into TiO₂ films can promote the appearance of regions with different charge dissipation capacities. © 2015 Society of Photo-Optical Instrumentation Engineers (SPIE) [DOI: 10.1117/1.JPE.5.057408]

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1 Introduction

Inverted hybrid bulk-heterojunction solar cells based on conjugated polymers and fullerene derivatives have attracted much attention because of their numerous advantages. These devices are considered promising candidates as renewable energy sources because of their low weight, low cost, stability and simple fabrication for large area processing.¹ These solar cells occupy a prominent position in the context of photovoltaic devices for solar energy conversion into electricity. This position is due to recent progress which allowed a significant increase in power conversion efficiency (PCE) of these cells, reaching nearly 10% over the last years.²⁻⁴ Additional understanding of the interfaces involved in the inverted hybrid bulk-heterojunction solar cells is needed and thus, the development of new materials becomes crucial to further improve the efficiency of these devices.

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Currently, there is a great interest in developing new materials to act as the electron transport layer (ETL) between the active layer and the conductive substrate in these devices.¹ The main requirements for a given film to act as ETL involve high electron mobility and transparency in the visible region in order to allow transmission of light into the active layer. These requirements limit the choice to a few materials that have these characteristics, among which are the well-known and widely used titanium oxide (TiO₂)^{5,6} and zinc oxide (ZnO).^{7,8} These materials also exhibit good compatibility with the lowest unoccupied molecular orbital energy level for the majority of polymers used and act as hole blocking layers preventing a short circuit in the device.

The use of TiO₂ films as ETL is advantageous due to their low toxicity, transparency, facile fabrication and well-known physical and chemical stability. In general, thin TiO₂ films have been introduced as ETL because of their large bandgap (3.7 eV) and well-matched energy levels (valence band of ~8.1 eV and conduction band of ~4.4 eV). Thus, these films facilitate the electron injection and transport; and at the same time, block the hole collection at the cathode.⁹ However, the slow charge carrier diffusion in a TiO₂ film increases the probability for charge recombination, resulting in decreased energy conversion efficiency of the solar cells. The promising alternative to improve the electronic transport is the incorporation of carbonaceous materials, such as carbon nanotubes (CNTs),¹⁰ graphene, and their derivatives,^{11,12} into TiO₂ films. In a recent work, Zhang et al.¹⁰ proposed the incorporation of CNTs in TiO₂ films to act as ETL in solar cells with the following configuration: ITO|TiO₂/CNTs|P3HT:PC₆₁BM|MoO₃|Al. In this work, they demonstrated that the conversion efficiency for these devices practically doubles with the addition of a small amount of CNTs (0.1 wt%). This influence was closely associated with the amount of CNTs. In addition, the devices assembled with TiO₂/multiwalled carbon nanotube (MWCNT) or TiO₂/single-walled carbon nanotube films showed similar photovoltaic behavior. In this context, due to the electron-accepting ability presented by these carbonaceous materials, there is also an interest in their use with the aim of improving the electron transport properties in semiconductor films.¹³

Graphene, a single layer of sp²-bonded carbon atoms tightly packed into a two-dimensional honeycomb structure, has attracted a lot of attention since its isolation in 2004, because of its outstanding mechanical, thermal, optical, and electrical properties.¹⁴ Various methods have been developed for the preparation of graphene, including micromechanical exfoliation,¹⁵ epitaxial growth,¹⁶ electrochemical exfoliation of graphite in ionic liquids,¹⁷ and the chemical modification of graphite.¹⁸ The latter method was proven to be an effective, inexpensive method and was often applied in large-scale production of this material. In this case, the graphene oxide (GO) product is an electrically insulating material and usually possesses a rich assortment of oxygen-containing groups such as carboxyl, hydroxyl, carbonyl, and epoxy groups.¹⁹ However, the GO sheets can be reduced by several methods^{20–23} in order to increase their electrical conductivity by the partial restoration of the sp²-hybridized network. In general, the resulting product, also known as reduced graphene oxide (RGO), has properties similar to graphene, although the reduction methods do not fully restore the ideal characteristics of graphene sheets.¹⁴ Due to its high surface area, transparency and its electron-accepting properties, RGO is a good material to enhance the charge carrier transport in semiconductor films, and consequently to improve the performance of the devices.²⁴

According to other reports, TiO₂/RGO nanocomposites have been widely investigated in photovoltaic devices,²⁵ photocatalysts,^{26,27} and lithium-ion batteries.²⁸ Recently, in the field of dye-sensitized solar cells (DSSC), graphene and its derivatives were employed as counter electrodes^{29,30} and TiO₂/RGO nanocomposites were used as a photoanode to improve the DSSC performance.^{31–33} Currently, there is an interest in using these nanocomposites as films to act as ETL in organic solar cells. In two recent works, Zhang et al.^{11,12} proposed the use of thin TiO₂/RGO films as ETL in inverted solar cells with the following configurations: ITO|TiO₂/RGO|P3HT:PC₆₁BM|MoO₃|Ag or ITO| and TiO₂/RGO|P3HT:PC₆₁BM|PEDOT:PSS|Ag. They reported that solar cells based on these composite films exhibit an improvement in the current density and also in the energy conversion efficiency. Impedance measurements revealed that the TiO₂/RGO composite films as ETL could efficiently reduce the charge recombination and increase the electron lifetime. Although the advantages of RGO sheet incorporation in any TiO₂ matrix are widely disseminated, a detailed explanation of the photovoltaic activity of these nanocomposites, as well the role of graphene and its derivatives is still very controversial and scarce in the literature. For this

reason, there is a need for further studies to improve the general understanding of the photovoltaic behavior when carbonaceous materials are used.

In this work, RGO was incorporated in TiO_2 films to be used as ETL in inverted hybrid bulk-heterojunction solar cells aiming to decrease the charge recombination and to increase the energy conversion efficiency. The solar cells were assembled with the following configuration: FTO/TiO_2 or $\text{TiO}_2/\text{RGO}/\text{P3HT}:\text{PC}_{61}\text{BM}/\text{V}_2\text{O}_5/\text{Ag}$. Compared to the solar cell using only TiO_2 as ELT, we observed that the incorporation of RGO (2.0 wt%) in the TiO_2 film showed an increase of 22.3% in J_{sc} and hence an improvement in the conversion efficiency. In this case, independent of the use of V_2O_5 or PEDOT:PSS films as the hole transport layer (HTL), the effect was positive after adding 2.0 wt% of RGO into the TiO_2 film. Kelvin probe force microscopy (KPFM) images suggest that the incorporation of RGO into TiO_2 film promotes the appearance of regions with different charge dissipation capacity. In others words, because of its conductive properties, the RGO can act as an electron collector in the TiO_2 film, which facilitates a rapid electron transport resulting in an increase in photocurrent and conversion efficiency.

2 Experimental Methods

2.1 Materials

All reagents were of analytical grade and used without further purification. The natural graphite powder was purchased from Nacional de Grafite LTDA (code: Micrograf 99507 UJ). Poly(3-hexylthiophene) (P3HT) (regioregular, Merck®, 98%) was used as the electron donor material, and [6,6]-phenyl- C_{61} -butyric acid methyl ester (PC_{61}BM) (Solenne BV, 99.5%) was used as the electron acceptor material in the inverted solar cells. All other reagents were purchased from Sigma-Aldrich. The fluorine-doped tin oxide (FTO) conductive substrates were supplied by SOLEMS (sheet resistance: 70 to 100 Ωsq^{-1}). The substrates were cleaned with water-detergent solution, deionized water and ethanol (99%) successively in ultrasonic baths for 15 min. All substrates were dried with compressed nitrogen and were treated in the UV surface decontamination system (Novascan, PSD-UV) connected to the oxygen supply for 20 min.

2.2 Synthesis of GO

GO was synthesized from natural graphite powder using a modified Hummers and Offeman's method.³⁴ The graphite powder (10 g) was added to a mixture of concentrated H_2SO_4 (60 mL), $\text{K}_2\text{S}_2\text{O}_8$ (5 g) and P_2O_5 (5 g). The solution was heated to 80°C in an oil bath and was stirred for 6 h. The mixture was then carefully diluted with distilled water, filtered, and washed until the rinse water pH turned neutral. The product was dried in air at ambient temperature overnight. The preoxidized graphite powder was added to a mixture of concentrated H_2SO_4 (200 mL) and NaNO_3 (5 g) under vigorous stirring, and the solution was cooled to 0°C. Next, 15 g of KMnO_4 was added gradually under stirring and the temperature of the mixture was kept below 20°C. The mixture was stirred at 40°C for 4 h, and then diluted with distilled water (2 L) in an ice bath. The reaction was terminated by the addition of 30% (v/v) H_2O_2 solution (50 mL) and a brilliant yellow product was formed along with bubbling. The mixture was filtered and washed with 3% (v/v) H_2SO_4 solution in order to remove metal ions. The GO product was suspended in distilled water to give a viscous and brown dispersion, which was subjected to dialysis to completely remove metal ions and acids. The resulting GO dispersion (1.8% w/w) was used in the preparation of thin TiO_2/RGO films.

2.3 Preparation of Thin TiO_2/RGO Film

Initially, the water present in the GO dispersion was removed to avoid immediate hydrolysis and condensation of the titanium isopropoxide $[\text{Ti}(\text{O}^i\text{Pr})_4]$, which is the precursor of TiO_2 . In this case, the solvent exchange was carried out as follows: an aliquot (~420 mg) of the aqueous GO dispersion (1.8% w/w) was dispersed first in ethanol and then diethyl ether was added, in a ratio of 1:5 (v/v). The GO precipitates due to the addition of a bad solvent (diethyl ether). After

removing the supernatant by centrifugation, the solvent exchange procedure was repeated to ensure complete removal of water. Evaporation of the solvent was carried out in a vacuum oven. The dry GO was redispersed in ethanol (3.0 mL) using an ultrasonic bath and then acetylacetone (140 μL) and $\text{Ti}(\text{O}^i\text{Pr})_4$ (200 μL) were added to the dispersion. The brown dispersion was designated as TiO_2/GO (4.0 wt%). The dispersion containing only TiO_2 was also prepared from a mixture of $\text{Ti}(\text{O}^i\text{Pr})_4$ (200 μL), acetylacetone (140 μL) and ethanol (3.0 mL). Other dispersions as TiO_2/GO (2.0 wt%), TiO_2/GO (1.0 wt%), TiO_2/GO (0.5 wt%), and TiO_2/GO (0.1 wt%) were prepared by dilution of the TiO_2/GO (4.0 wt%) using the dispersion containing only TiO_2 as the diluent. The TiO_2 and TiO_2/GO dispersions were deposited on the FTO substrates by spin-coating followed by thermal treatment at 350°C for 1 h with a heating rate of $10^\circ\text{C min}^{-1}$. This thermal treatment step is very important to remove the organic materials and also to reduce GO to RGO, which is a more conductive material than GO. The resulting films, with a thickness around 30 to 60 nm as estimated by the scanning electron microscopy (SEM) images (see Fig. 13 in Appendix), were transparent and uniform without any noticeable cracks. All the nanocomposite films were denominated as TiO_2/RGO .

2.4 Characterization

X-ray diffraction measurements were performed directly on the samples of GO, RGO, TiO_2 and TiO_2/RGO films using a Shimadzu XRD 7000 diffractometer (40 kV, 30 mA) with Cu ($\lambda = 1.54178 \text{ \AA}$) irradiation in the 2θ range of 5 to 80 deg. The Raman spectra of the samples were obtained in a confocal Raman spectrometer (model T64000, Jobin Yvon, USA), equipped with a charge coupled device detector and an Olympus BTH 2 microscope. The excitation laser was set at 514 nm with a 20-fold magnification objective lens. The thermal stability of the lyophilized GO sample was analyzed on TA Instruments 2950 thermogravimetric analyzer at a heating rate of $10^\circ\text{C min}^{-1}$, using a synthetic air stream ($100 \text{ dm}^3 \text{ min}^{-1}$) in the temperature range of 50°C to 1000°C and the average sample weight was within the range of 3 to 5 mg.

A Thermo VG Scientific Sigma Probe instrument was used to carry out the x-ray photoelectron spectroscopy (XPS) analysis of the GO and RGO (350°C for 1 h) films. The monochromatic Al $K\alpha$ x-ray source (1486.6 eV) was focused on the sample ($400 \mu\text{m}^2$ size). The high resolution spectra were collected with a pass energy of 20 eV and an energy step size of 0.1 eV with the flood gun turned on to eliminate any surface charge. TiO_2 and TiO_2/RGO films deposited onto FTO substrates were characterized by atomic force microscopy (AFM) and KPFM analysis. AFM and KPFM measurements were obtained simultaneously using a NX10 Atomic Force Microscope from Park Systems in the tapping mode with a three lock-in module. The KPFM images were obtained in dry atmosphere and an electrical frequency of 17 kHz with an amplitude of 5 V was used. A Pt/Ir-coated tip with a mechanical resonance frequency of 75 kHz and a force constant of 2.8 N m^{-1} was used.

Optical microscopy images were taken with a Nikon Eclipse 5i (H5505, Nikon, Japan) microscope equipped with Digital Sight Camera System (DS-Fi1 Nikon, Japan) and using an objective lens with a magnification of $4\times/0.10$. The optical absorption spectra of the TiO_2 and the TiO_2/RGO films were measured by using a Varian spectrophotometer, model Cary 5G UV-VIS, NIR, with a diffuse reflectance accessory. Measurements were carried out within the range of 300 to 800 nm, using Teflon as a reference material for all samples.

2.5 Fabrication of Photovoltaic Devices

In this work, we fabricated inverted hybrid bulk-heterojunction solar cells with the following configuration: $\text{FTO}|\text{TiO}_2/\text{RGO}|\text{P3HT}:\text{PC}_{61}\text{BM}|\text{V}_2\text{O}_5|\text{Ag}$. First, solutions of P3HT and PC_{61}BM were prepared with 1:1 ratio and the total concentration of P3HT: PC_{61}BM was 60 mg mL^{-1} in chlorobenzene. On the FTO substrates coated with thin TiO_2 and TiO_2/RGO films, the P3HT: PC_{61}BM solution was spin-coated at 1000 rpm and the thickness of the active layer was about 200 nm. The films were annealed at 150°C for 15 min in an N_2 -filled glove box. The V_2O_5 hydrate solution was obtained using the procedure described in the literature.³⁵ In this case, a 1:1 mixture of V_2O_5 hydrate (9 mg mL^{-1}) in isopropanol was spin-coated at 3000 rpm on the $\text{FTO}|\text{TiO}_2$ or $\text{TiO}_2/\text{RGO}|\text{P3HT}:\text{PC}_{61}\text{BM}$ and then annealed at 150°C

for 15 min in an N_2 -filled glove box. A 100-nm thick Ag back metal electrode was deposited by thermal evaporation in an evaporation system (Auto 306, Boc Edwards) with a base pressure of 10^{-7} torr at the deposition rate of 1.0 \AA s^{-1} . The final active area was 0.17 cm^2 . The configuration of the devices (FTO|TiO₂/RGO|P3HT:PC₆₁BM|V₂O₅|Ag) and the chemical structures of P3HT and PC₆₁BM are shown in Fig. 1.

For other the configuration (FTO|TiO₂/RGO|P3HT:PC₆₁BM|PEDOT:PSS|Ag), the PEDOT:PSS layer was spin-coated at 5000 rpm over the active layer (FTO|TiO₂/RGO|P3HT:PC₆₁BM). The PEDOT:PSS commercial solution was modified by the addition of the surfactant (Zonyl FS300) with a ratio of Zonyl : PEDOT:PSS equal to 0.5% w/w. The films were annealed at 150°C for 15 min in an N_2 -filled glove box. A 100-nm thick Ag back metal electrode was deposited by thermal evaporation as described previously.

2.6 Photovoltaic Characterization

The solar simulation was performed on a KHS1200 (Steuernagel Solarkonstant) equipped with an AM1.5 filter for all characterizations (100 mW cm^{-2} , AM1.5G). The equipment was calibrated according to the ASTM G173 standard. J - V curves were measured using a Keithley 2601 multimeter. The light intensity was calibrated to 100 mW cm^{-2} with a Zipp&Konen CM-4 pyranometer, which was used constantly during measurements to set the light intensity, and a calibrated S1227-1010BQ photodiode from Hamamatsu was also used for calibration before each measurement. Incident photon-to-current conversion efficiency (IPCE) analyses were done with a QE/IPCE measurement System from Oriel (from 300 to 700 nm; at 10 nm intervals). The results were not corrected for any intensity losses due to light absorption or reflection by the glass substrates.

3 Results

3.1 Morphological and Structural Characterization of the GO and RGO Films

The GO and RGO films were characterized through x-ray diffraction and Raman spectroscopy, and the results are shown in Figs. 2(a) and 2(b), respectively.

According to Fig. 2(a), the XRD diffraction pattern of the GO film exhibits a peak at $2\theta = 10.7^\circ$ corresponding to an interplanar spacing of $d(002) = 8.3 \text{ \AA}$. Other diffraction peaks correspond to the crystalline phases of the FTO conductive substrate, and these are marked with asterisks (*). The increased interplanar distance from the characteristic peak of graphite (3.35 \AA) is related to the presence of oxygen-containing functional groups and water molecules introduced into the carbon lattice during the oxidation.³⁶ When the GO film is heat-treated at 350°C for 1 h, the 2θ peak at 10.7° disappears and a broader and weaker peak centered at around $2\theta = 21.5^\circ$ with a interplanar spacing of $d(002) = 4.1 \text{ \AA}$ is observed. This implies that the oxygen-containing functional groups of GO were partially removed through thermal treatment and without adding any reducing agent.³⁷ There is also a noticeable decrease in the intensity of the diffraction peak due to the loss of crystallinity of the material, with the formation of more disordered, less packed structures.

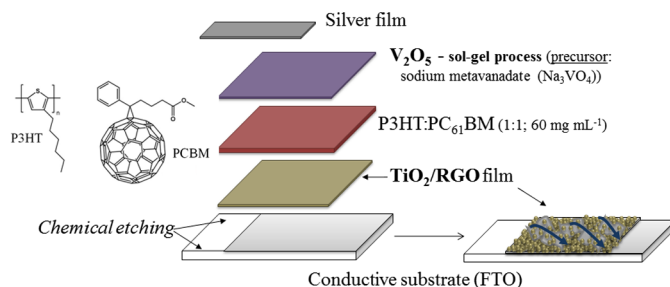


Fig. 1 Representation of the inverted solar cell assembled with the following configuration: FTO|TiO₂/RGO|P3HT:PC₆₁BM|V₂O₅|Ag. Chemical structures of the P3HT and the PC₆₁BM.

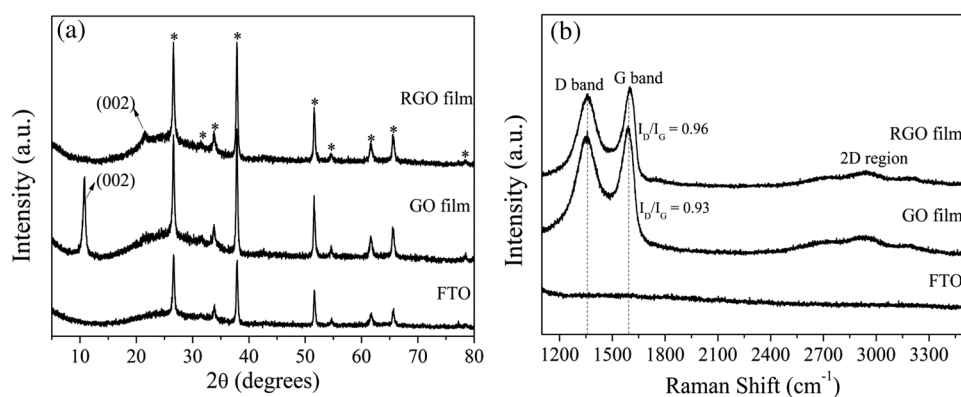


Fig. 2 (a) X-ray diffraction patterns and (b) Raman spectra for FTO substrate, GO, and RGO (350°C for 1 h) films.

The Raman spectra [Fig. 2(b)] of the GO and RGO films exhibit three vibrational modes at 1360, 1600 and 2700 cm^{-1} , corresponding to the D, G and 2-D bands, respectively. The G band is related to the E_{2g} vibration mode of the sp^2 carbon domains and it can be used to ascertain the degree of graphitization, whereas the D band is associated with structural defects and partially disordered structures of the sp^3 domains. The 2-D band is the second order of the D band and its frequency is generally used to quantify the number of graphene layers and stacking order in few-layers graphene.^{38,39} The intensity ratio between the D and G bands (I_D/I_G) is often used as a parameter to correlate the disorder degree in the carbonaceous structures.³⁸ In this case, the I_D/I_G ratio was 0.93 for the GO film and 0.96 for the RGO film. This small change suggests that a decrease in the average size of the sp^2 domains formed during the thermal treatment at 350°C for 1 h. It is reasonable to consider that the reduction of GO causes fragmentation along the reactive sites and yields new graphitic domains, which led to the RGO sheets being smaller but more numerous. The small size of the RGO sheets will result in a large number of edges. The edges will act as defects. This explains the presence of the D band, with considerable intensity, even after the thermal reduction of GO.^{40,41} Furthermore, the thermal treatment at 350°C for 1 h promoted the partial removal of the labile oxygen-containing functional groups, as proposed in the thermogravimetric analysis (TGA) curve obtained for the lyophilized GO sample (see Fig. 13 in Appendix).⁴²

XPS was used to determine the chemical composition of the GO and RGO (350°C for 1 h) films. XPS survey spectra (up to 1000 eV) were obtained to identify and quantify the elements and chemical groups present in these samples, as shown in Fig. 14 (see in Appendix). The spectra essentially showed the presence of the elements carbon (C1s) and oxygen (O1s) in the region around 284 and 532 eV, respectively. Table 3 (see in Appendix) details the atomic percentages found in these samples. In the RGO film, the C percentage was 85.2 at% (and 14.8 at% of O), compared to 67.0 at% (and 33.0 at% of O) in the GO film. This is an indication that the oxygen-containing functional groups have been partially removed after the thermal treatment at 350°C for 1 h. High resolution XPS C1s spectra obtained for these films are shown in Fig. 3.

The XPS C1s peak of the GO film [Fig. 3(a)] can be decomposed into seven components which correspond to the following functional groups: sp^2 -hybridized carbon ($\text{C}=\text{C}$, 284.2 eV), sp^3 -hybridized carbon ($\text{C}-\text{C}$, 284.9 eV), hydroxyl/phenols ($\text{C}-\text{OH}$, 285.5 eV), epoxy/ether ($\text{C}-\text{O}-\text{C}$, 286.4 eV), carbonyl ($\text{C}=\text{O}$, 287.7 eV), carboxyl ($\text{O}-\text{C}=\text{O}$, 288.7 eV) groups and a shake-up satellite peak ($\pi \rightarrow \pi^*$, 289.8 eV), characteristic of aromatic C structures.^{43–45} The XPS C1s analysis suggests that the GO film contains a large number of functional groups on its surface such as epoxy, carbonyl, hydroxyl, and carboxyl groups. The XPS spectrum of the RGO film [Fig. 3(b)] shows that the same peaks are related to the oxygen containing functional groups, however, they are much less intense. Through this analysis, it was possible to demonstrate the presence of oxygen functional groups on the surface even after a reduction process by thermal treatment at 350°C for 1 h, indicating that the GO film was not fully reduced. However, it was sufficient to increase the aromatic character of the material, turning RGO into a more conductive material than the GO.^{40,46–48} Another interesting fact can be evidenced in Table 4 (see Appendix) where the concentration of $\text{C}=\text{C}$ bonds ($\sim 53\%$) found in the RGO film is larger than

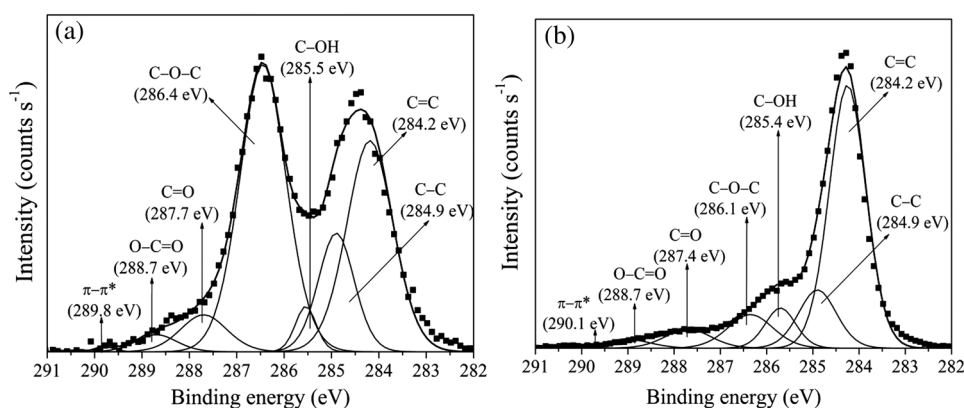


Fig. 3 XPS spectrum of the carbon region (C1s) for (a) GO and (b) RGO (350°C for 1 h) films.

the GO film ($\sim 32\%$). This is another evidence of almost complete restoration of the sp^2 -hybridized network in the RGO film after thermal treatment.

3.2 Morphological and Structural Characterization of the TiO_2 /RGO Films

Figure 4 exhibits the XRD diffraction pattern and the Raman spectra of the FTO substrate, TiO_2 , TiO_2 /RGO (2.0 wt%) films and TiO_2 /RGO (2.0 wt%) powder when subjected to thermal treatment at 350°C for 1 h.

The crystal planes corresponding to the titanium oxide were not observed directly in the XRD diffraction pattern in Fig. 4(a). This can be due to the overlap from other diffraction peaks that correspond to crystalline phases of the FTO substrate [marked with asterisks (*)]. The x-ray diffraction patterns obtained for the TiO_2 /RGO (2.0 wt%) powder exhibit a good crystallinity. The peaks at 2θ values of 25.2, 37.8, 47.9, 53.9, 55.1, 62.6, 68.9, 70.2 and 75.2 deg can be indexed to (101), (004), (200), (105), (211), (204), (220), (116), and (215) planes of anatase titania, respectively. No diffraction peak was detected for the carbon species in the films, due to both the low concentration and the low relative intensity of the main diffraction peak for RGO [see Fig. 2(a)]. However, the Raman spectra [Fig. 4(b)] showed wide and less intense bands vibrations in the region between 300 and 800 cm^{-1} which are associated with the titanium oxide. In the TiO_2 /RGO (2.0 wt%) film, the presence of RGO was confirmed with the appearance of three vibrational modes at 1358, 1607 and 2690 cm^{-1} related to D, G and 2-D bands, respectively. The I_D/I_G ratio around 1.0 suggests a relative increase in structural disorder in relation to the film containing only RGO ($I_D/I_G = 0.96$), possibly because of the interaction between the RGO sheets and TiO_2 nanoparticles.

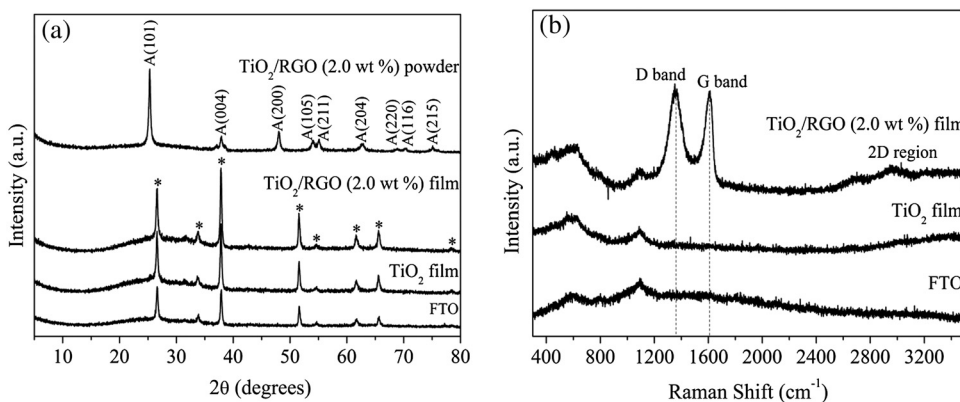


Fig. 4 (a) X-ray diffraction patterns for FTO substrate, TiO_2 , TiO_2 /RGO (2.0 wt%) films, and TiO_2 /RGO (2.0 wt%) powder. (b) Raman spectra for FTO substrate, TiO_2 , and TiO_2 /RGO (2.0 wt%) films.

Optical microscopy images (Fig. 5) of the TiO_2 , TiO_2/RGO (0.1 wt%), TiO_2/RGO (0.5 wt%), TiO_2/RGO (1.0 wt%), TiO_2/RGO (2.0 wt%), and TiO_2/RGO (4.0 wt%) films were obtained in order to evaluate how the RGO sheets are distributed throughout the TiO_2 film.

In this case, the RGO sheets are well distributed throughout the composite films, probably on the surface, independent of the RGO concentration. In addition, the size and shape of the RGO sheets vary widely for all the TiO_2/RGO films. The increased surface roughness of the composite films with increasing RGO concentration was also observed through these images. The TiO_2/RGO (4.0 wt%) film [Fig. 5(f)], for example, shows many regions with agglomerations of the RGO sheets providing a rougher appearance compared to the other composite films. Another important factor to be considered is the thickness of the TiO_2 and TiO_2/RGO films, estimated in this work through SEM images obtained by the cross-section of all films.

Figure 13 (see in Appendix) illustrates a graph relating thickness variation versus the concentration of RGO (%) for each film. This graph shows that the thickness increased significantly from 32.2 to 58.5 nm when the concentration of RGO ranged from 0 to 1.0 wt%. At higher RGO concentrations, the thickness has not changed significantly. The TiO_2/RGO (4.0 wt%) film, for example, presented a thickness of about 61 nm, which is relatively close to the value measured for the TiO_2/RGO (1.0 wt%) film (~ 58.3 nm). The increased thickness of the films is directly related to the increased viscosity of the TiO_2 dispersions due to the addition of GO. In general, these features, such as roughness and thickness, influence the performance of the photovoltaic devices.

In order to investigate the morphological effect of the introduction of RGO in TiO_2 films, AFM images were obtained and presented in Fig. 6. The AFM image shows that the FTO substrate has a surface roughness around 7.6 nm and a homogeneous size distribution and grain shape. The film containing only TiO_2 has a low surface roughness ($\text{RMS} = 3.5 \pm 0.1$ nm). The decrease in roughness is related to coating of the FTO substrate by the thin TiO_2 film. The addition of RGO significantly changes the morphology of the TiO_2 films, with loss of uniformity and increase in surface roughness. With the addition of RGO (2.0 wt%) and (4.0 wt%), the surface roughness was 16.2 ± 1.6 and 12.6 ± 0.8 nm, respectively. Tsai et al.⁴⁹ observed the same behavior: the increase in roughness with increasing amount of RGO incorporated into TiO_2 films is not linear, due to the heterogeneity of the composite films. The AFM images for the TiO_2/RGO films also show that a part of the RGO sheets are on the surface of the TiO_2 film. We also found other regions in the AFM images where the RGO sheets are decorated with TiO_2 nanoparticles. In conclusion, we obtain a heterogeneous mixture between the two components: RGO and TiO_2 .

KPFM measurements were obtained in the same area of the AFM images to compare the electric potential distribution on the surface of the FTO substrate, TiO_2 and TiO_2/RGO films.

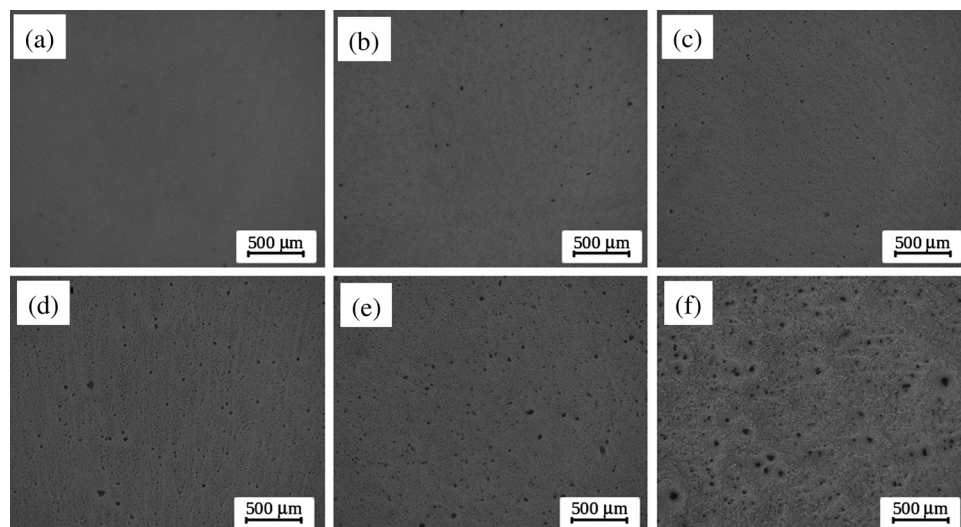


Fig. 5 Optical microscopy images of the (a) TiO_2 , (b) TiO_2/RGO (0.1 wt%), (c) TiO_2/RGO (0.5 wt%), (d) TiO_2/RGO (1.0 wt%), (e) TiO_2/RGO (2.0 wt%) and (f) TiO_2/RGO (4.0 wt%) films.

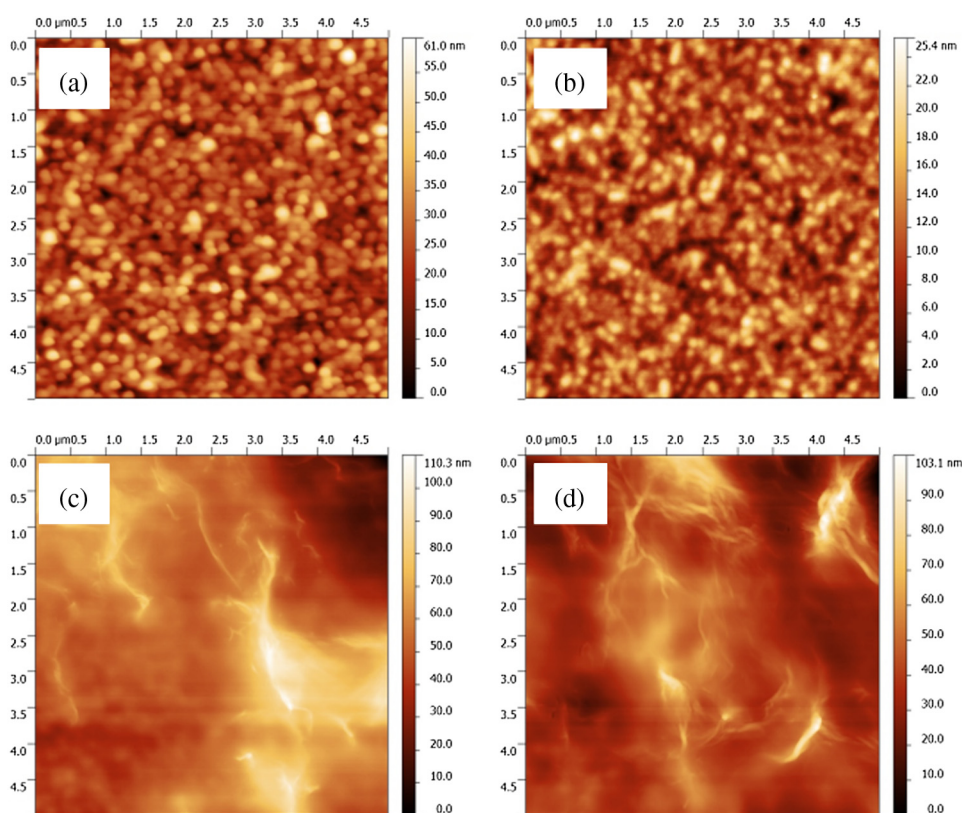


Fig. 6 AFM images of the (a) FTO substrate, (b) TiO_2 , (c) TiO_2/RGO (2.0 wt%), and (d) TiO_2/RGO (4.0 wt%) films.

The voltage profiles of the substrate and films, obtained in $5 \times 5 \mu\text{m}^2$ sections, are presented in Fig. 7. The average surface potential (SP) values for the FTO substrate, TiO_2 and TiO_2/RGO films were calculated. The FTO substrate presented a homogeneous electric potential distribution with average SP value of -0.86 V. The substrate was used as reference and the relative SP values were obtained for TiO_2 and TiO_2/RGO films.⁵⁰ For the TiO_2 films, a homogeneous electric potential distribution with little contrast is found, being the relative SP of -0.07 V. The SP of the films after incorporation of RGO (2.0 wt%) increased to 0.18 V, and the potential distribution becomes heterogeneous, allowing a clearer view of regions with different charge densities. The effect observed in TiO_2/RGO (4.0 wt%) film is a more positive shift in SP values, however, the electrical potential is a little more homogeneous. The changes in the electrical potential show that after RGO introduction, regions with different charge dissipation capacity were created. In a previous work, we studied $\text{TiO}_2/\text{MWCNT}$ composite films and the variation of SP of the films was attributed to grain boundaries, showing different charge densities between the grains and the interfaces.⁵¹ Even with a substantial difference between the surface roughness of the films containing TiO_2 and TiO_2/RGO , as demonstrated by AFM images, the change in SP of the TiO_2 film after the addition of RGO is significant, indicating that the grains have a relative difference in charge density between themselves and their interfaces.

Liscio et al.⁵² demonstrated that introduction of TiO_2 nanorods into P3HT film promotes the decrease in SP, improving the charge dissipation in active layers. Under illumination, negative shifts in SP were observed for P3HT/ TiO_2 bulk heterojunction deposited under ITO/PEDOT:PSS substrates. This fact was attributed to the photogenerated electrons and the hole drift to ITO.⁵² In inverted hybrid bulk-heterojunction solar cells using $\text{TiO}_2/\text{reduced GO}$ films, electrons are referred to the FTO substrate. The introduction of reduced GO into TiO_2 films promotes a positive shift in SP values. This shift can suggest that electrons are transported to the FTO substrate, while holes remain in the TiO_2/RGO surface. Thus, the electron collection capacity can be increased with the addition of RGO.

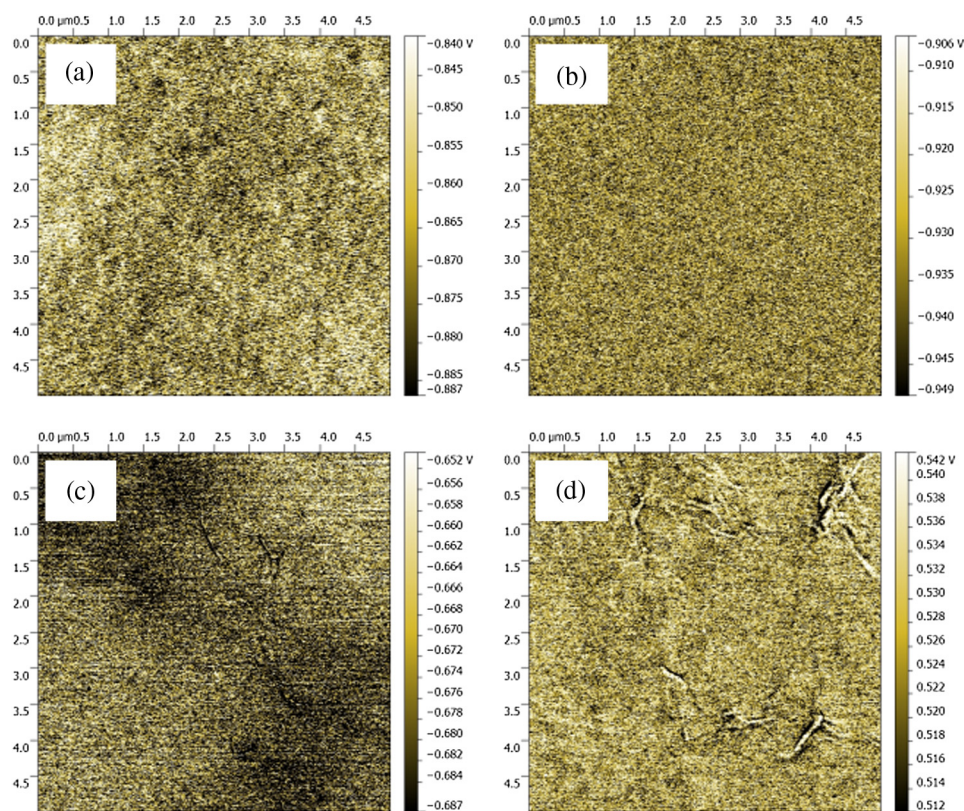


Fig. 7 KPFM images of the (a) FTO substrate, (b) TiO_2 (c) TiO_2/RGO (2.0 wt%), and (d) TiO_2/RGO (4.0 wt%) films.

Figure 8 shows the UV-visible absorption spectra of the TiO_2 and TiO_2/RGO films. A significant increase in the absorption at wavelengths shorter than 400 nm is assigned to the intrinsic band gap absorption of the titanium oxide (~ 3.2 eV).⁵³ The presence of RGO significantly affects the light absorption in all TiO_2/RGO films. Films with higher amounts of RGO resulted in darker films showing an increase in light adsorption within the investigated region. This behavior will have an important implication in the efficiency of photovoltaic devices, as will be discussed in the next section.

3.3 Photovoltaic Performance of the Devices

The inverted hybrid bulk-heterojunction solar cells ($\text{FTO}|\text{TiO}_2$ or $\text{TiO}_2/\text{RGO}|\text{P3HT}:\text{PC}_{61}\text{BM}|\text{V}_2\text{O}_5|\text{Ag}$) were characterized using $J-V$ curves obtained under illumination

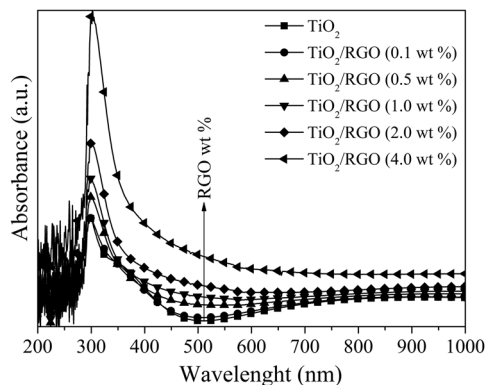


Fig. 8 UV-vis absorption spectra for the thin TiO_2/RGO films.

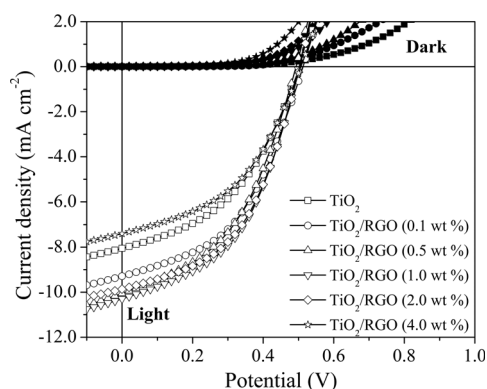


Fig. 9 $J-V$ curves for the inverted hybrid bulk-heterojunction solar cells (FTO|TiO₂ or TiO₂/RGO|P3HT:PC₆₁BM|V₂O₅|Ag) using TiO₂, TiO₂/RGO (0.1 wt%), TiO₂/RGO (0.5 wt%), TiO₂/RGO (1.0 wt%), TiO₂/RGO (2.0 wt%), and TiO₂/RGO (4.0 wt%) films as ETL; under illumination (100 mW cm⁻², AM 1.5G) and dark conditions. Active cell area: 0.17 cm².

(100 mW cm⁻², AM 1.5G) and dark conditions. The effect of incorporation of different amounts of RGO into the TiO₂ film was studied and the results are shown in Fig. 9.

The performance of the devices was dependent on the concentration of RGO incorporated into TiO₂ films. The $J-V$ curves show that at low concentrations of RGO (<2.0 wt%), there was a marked increase in the short circuit current density (J_{sc}) and fill factor (FF) values. Noticeably, there was only a small difference between the results with the TiO₂/RGO films containing 0.1, 0.5, 1.0, and 2.0 wt% of RGO. However, a dramatic decrease in performance was observed using TiO₂ films containing a higher concentration of RGO (4.0 wt%). In this case, the increased charge recombination was one of the main factors of the decline in the efficiency of these devices and this effect can also be evidenced by observing the $J-V$ curves in the dark (Fig. 9).

For the investigation of the effect of the RGO concentration in the TiO₂ film, seven different devices ($n = 7$) for each concentration of RGO were assembled and then the average and standard deviation of the results were obtained. Table 1 shows the photovoltaic parameters short circuit current density (J_{sc}), open circuit potential (V_{oc}), FF, PCE, series resistance (R_s), and shunt resistance (R_{sh}), calculated from the $J-V$ curves obtained in the inverted solar cells using TiO₂ films with different concentrations of RGO as ETL. Graphs for all photovoltaic parameters (J_{sc} , V_{oc} , FF, PCE, R_s , and R_{sh}) were constructed with their respective average and standard deviation versus the concentration of RGO in the TiO₂ film shown in Fig. 10.

As shown in Table 1, when the concentration of RGO increases from 0 to 2.0 wt% in the TiO₂ film, the average J_{sc} increases from 7.94 to 9.71 mA cm⁻², and then decreases to 7.41 mA cm⁻² when the amount of RGO is further increased (4.0 wt%). This behavior is apparent in Fig. 10(a),

Table 1 Photovoltaic parameters obtained for inverted hybrid bulk-heterojunction solar cells (FTO|TiO₂ or TiO₂/RGO|P3HT:PC₆₁BM|V₂O₅|Ag) using TiO₂, TiO₂/RGO (0.1 wt%), TiO₂/RGO (0.5 wt %), TiO₂/RGO (1.0 wt %), TiO₂/RGO (2.0 wt %), and TiO₂/RGO (4.0 wt %) films as ETL. Active cell area: 0.17 cm².

Films	J_{sc} (mA cm ⁻²)	V_{oc} (V)	FF (%)	PCE (%)	R_s (10 ⁵ Ω)	R_{sh} (10 ⁵ Ω)
TiO ₂	7.94 ± 0.66	0.51 ± 0.01	44.0 ± 1.22	1.80 ± 0.18	1.39 ± 0.34	1.15 ± 0.16
TiO ₂ /RGO (0.1 wt%)	9.43 ± 0.16	0.51 ± 0.01	45.5 ± 1.39	2.20 ± 0.13	1.16 ± 0.08	1.27 ± 0.17
TiO ₂ /RGO (0.5 wt%)	9.59 ± 0.58	0.50 ± 0.01	45.4 ± 0.56	2.19 ± 0.11	1.11 ± 0.05	1.28 ± 0.09
TiO ₂ /RGO (1.0 wt%)	9.49 ± 0.61	0.51 ± 0.01	46.0 ± 1.39	2.22 ± 0.12	1.13 ± 0.11	1.33 ± 0.10
TiO ₂ /RGO (2.0 wt%)	9.71 ± 0.50	0.51 ± 0.01	47.4 ± 2.26	2.32 ± 0.07	1.02 ± 0.12	1.38 ± 0.15
TiO ₂ /RGO (4.0 wt%)	7.41 ± 0.58	0.51 ± 0.01	42.4 ± 3.25	1.58 ± 0.14	1.66 ± 0.28	1.38 ± 0.15

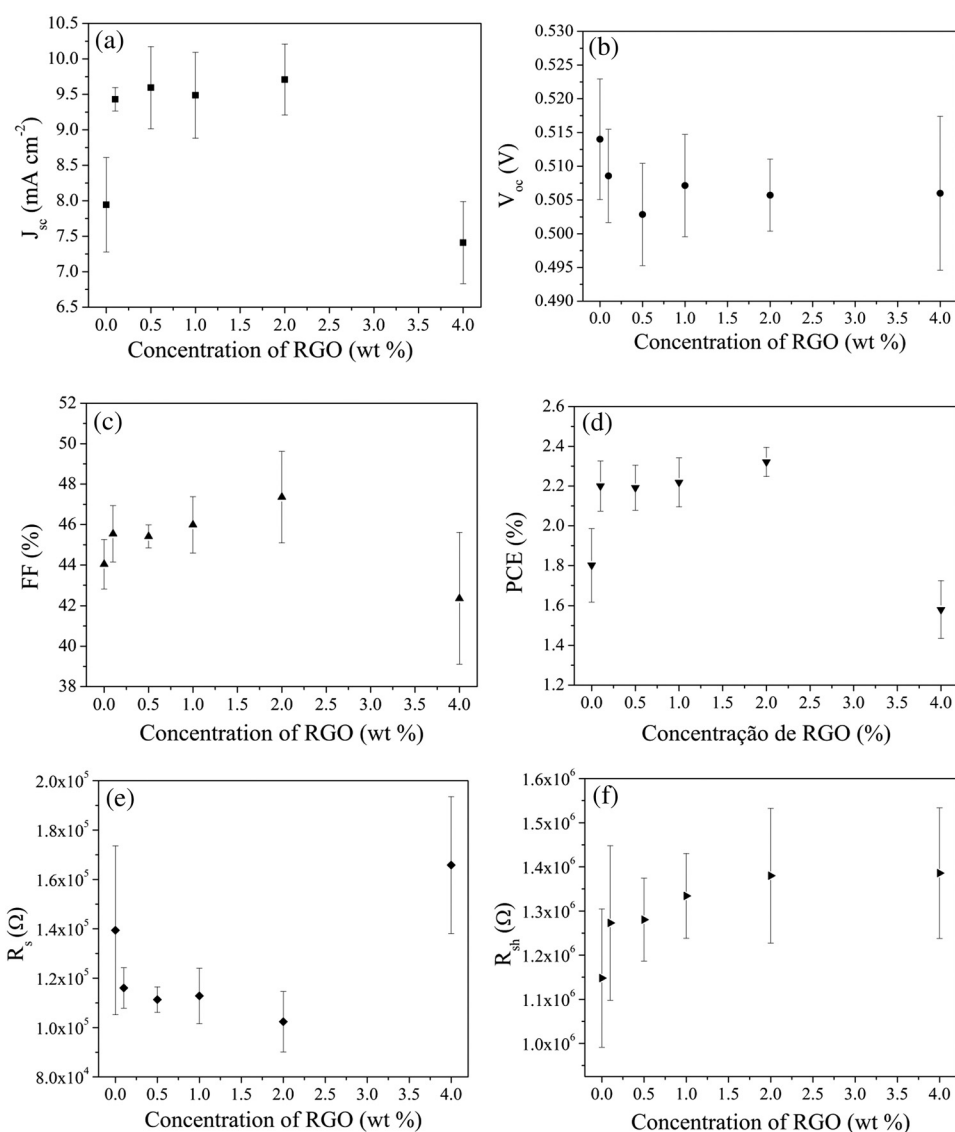


Fig. 10 Variation of the photovoltaic parameters obtained for inverted hybrid bulk-heterojunction solar cells using TiO₂ films with different RGO concentration. (a) J_{sc} , (b) V_{oc} , (c) FF, (d) PCE, (e) R_s e (f) R_{sh} . Configuration: FTO|TiO₂ or TiO₂/RGO|P3HT:PC₆₁BM|V₂O₅|Ag. Active cell area: 0.17 cm⁻².

which represents a graph of the variation of J_{sc} versus the concentration of RGO. Thus, the TiO₂/RGO (2.0 wt%) film showed a 22.3% higher average J_{sc} compared to the TiO₂ film, followed by a decrease of 23.7% when using the TiO₂/RGO film (4.0 wt%). There was no significant difference in the average J_{sc} values between the TiO₂/RGO films containing 0.1, 0.5, 1.0 and 2.0 wt% of RGO. We propose that a low concentration of RGO (<2.0 wt%) is sufficient to introduce an alternative conduction pathway, which facilitates a rapid electron transport in the TiO₂ films, as suggested from KPFM images (Fig. 7). A similar behavior was observed by Lee et al.¹³ who proposed the use of ZnO:RGO films to act as ETL in inverted solar cells using the following configuration: ITO|ZnO:RGO|P3HT:PC₆₁BM|PEDOT:PSS|Ag. The study reported that the increase in J_{sc} is related to the increase in conductivity of the film and reduction of the interfacial resistance between the composite film and the active layer, evidenced in electrochemical impedance measurements. In this case, due to its conductive properties, the RGO sheets can also act as an electron collector in the TiO₂ film, resulting in an increase in photocurrent and conversion efficiency. We also propose that a higher concentration of RGO (4.0 wt%) promotes an increase of the light absorption due to film darkening, as shown in

Fig. 8, and agglomerations of RGO sheets are observed in Fig. 5(f). These factors caused a marked decrease of J_{sc} and, therefore, a decrease in the performance of the devices.

Figure 10(b) shows that the average V_{oc} values did not vary significantly with increasing concentration of RGO, remaining almost constant around 0.51 V. On the other hand, there was a relative increase in average FF values due to the presence of RGO, with only the TiO_2 /RGO (4.0 wt%) film showing a drop. Figure 10(c) shows a relative increase of 7.7% in the FF of the TiO_2 /RGO (2.0 wt%) film compared to the TiO_2 film. The decrease in FF to 42.4% in the TiO_2 /RGO (4.0 wt%) films is directly related to the increase in the R_s ($1.66 \times 10^5 \Omega$) as shown in Fig. 10(e). The addition of RGO can reduce the R_s between the FTO and active layer, promoting efficient electron transfer to the electrodes. For higher amounts of RGO, an increase in R_s was observed due to the large resistance toward out-of-the plane conduction among RGO sheets.^{54,55} The TiO_2 /RGO film thickness (see in Fig. 13 in Appendix) is also a determining factor for a solar cell. In this case, for thick TiO_2 /RGO films, the electron transport path becomes longer and, therefore, there is an increased probability of charge recombination. Because of this, the R_s values may be relatively high. Regarding the R_{sh} values plotted in Fig. 10(f), there was a small increase in these values with the incorporation of RGO in the TiO_2 film. These factors directly affect the PCE of these devices, which when combined caused an improvement from 1.80 to 2.32% with the addition of RGO (0 to 2.0 wt%) and a reduction to 1.58% with the TiO_2 /RGO (4.0 wt%) film.

To understand the different photocurrent characteristics of inverted solar cells fabricated with TiO_2 /RGO films, the IPCE spectra as a function of wavelength from 300 to 800 nm were collected. Figure 11 represents the IPCE spectra obtained for the devices (FTO/ TiO_2 or TiO_2 /RGO/P3HT:PC₆₁BM/ V_2O_5 /Ag) using TiO_2 films containing different concentrations of RGO as ETL.

According to the IPCE spectra (Fig. 11), a maximum at 520 nm for all analyzed devices was observed, which related to the wavelength where the P3HT polymer has a maximum absorption.⁵⁶ The IPCE spectra display a clear increase in IPCE with a higher RGO content in the TiO_2 film. The largest IPCE is seen for the device assembled with TiO_2 /RGO (1.0 wt%) and TiO_2 /RGO (2.0 wt%) film due to the increased conductivity and decrease of R_s [see Fig. 10(e)]. Therefore, this device has a maximum IPCE around 49.3%, which is 18.2% higher than in the pristine TiO_2 film [$IPCE_{(520\text{ nm})} \sim 41.7\%$]. Other films such as TiO_2 /RGO (0.1 wt%) and TiO_2 /RGO (0.5 wt%) showed maximum IPCE values in the region near 520 nm around 45.1% and 48.3%, respectively. By contrast, the TiO_2 /RGO (4.0 wt%) film showed a maximum IPCE of 38.4% due to the increased R_s [see Fig. 10(e)], resulting in an increase of charge recombination and a decrease in the performance of these devices. The integrated photocurrent based on the IPCE data is in agreement with the photocurrent data [Fig. 10(a)] measured using the solar simulator, with an error of about 10% (see in Table 5 in Appendix).

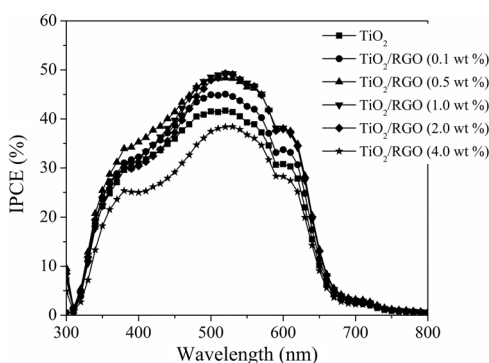


Fig. 11 IPCE spectra for inverted hybrid bulk-heterojunction solar cells (FTO/ TiO_2 or TiO_2 /RGO/P3HT:PC₆₁BM/ V_2O_5 /Ag) using TiO_2 , TiO_2 /RGO (0.1 wt%), TiO_2 /RGO (0.5 wt%), TiO_2 /RGO (1.0 wt%), TiO_2 /RGO (2.0 wt%), and TiO_2 /RGO (4.0 wt%) films as ETL. Active cell area: 0.17 cm^{-2} .

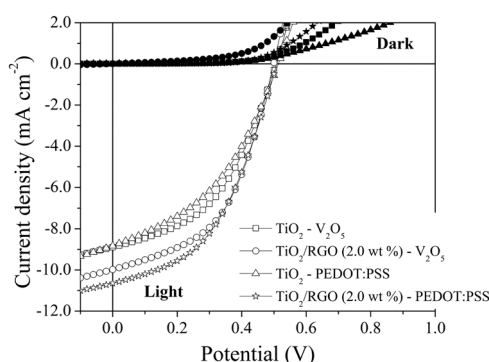


Fig. 12 $J-V$ curves for the inverted hybrid bulk-heterojunction solar cells (FTO|TiO₂ or TiO₂/RGO (2.0 wt%)|P3HT:PC₆₁BM|V₂O₅ or PEDOT:PSS|Ag) using TiO₂ or TiO₂/RGO (2.0 wt%) films as ETL, under illumination (100 mW cm⁻², AM 1.5G) and dark conditions. Active cell area: 0.17 cm².

Table 2 Photovoltaic parameters obtained for inverted hybrid bulk-heterojunction solar cells (FTO|TiO₂ or TiO₂/RGO|P3HT:PC₆₁BM|V₂O₅ or PEDOT:PSS|Ag) using TiO₂ or TiO₂/RGO (2.0 wt%) films as ETL. Active cell area: 0.17 cm².

Films	HTL	J_{sc} (mA cm ⁻²)	V_{oc} (V)	FF (%)	PCE (%)	R_s (10 ⁵ Ω)	R_{sh} (10 ⁶ Ω)
TiO ₂	V ₂ O ₅	8.89	0.51	45.8	2.06	1.07	1.35
TiO ₂ /RGO (2.0 wt%)	V ₂ O ₅	9.98	0.51	49.2	2.45	0.82	1.29
TiO ₂	PEDOT:PSS	8.83	0.51	41.2	1.87	1.46	1.05
TiO ₂ /RGO (2.0 wt%)	PEDOT:PSS	10.65	0.51	46.0	2.49	1.06	1.51

The proposal of using thin V₂O₅ films as HTL is because of its higher stability to the ambient atmosphere relative to PEDOT:PSS, which has been shown to be detrimental for organic solar cells due to its high hygroscopic capacity and its acidic pH Ref. 35. The best results obtained by inverted solar cells using TiO₂ or TiO₂/RGO (2.0 wt%) as ETL and V₂O₅ or PEDOT:PSS as HTL are shown in Fig. 12. This study aimed to compare the photovoltaic behavior between the devices based on V₂O₅ and PEDOT:PSS as HTL.

In general, the photovoltaic behavior is relatively similar between the devices with configuration FTO|TiO₂|P3HT:PC₆₁BM|V₂O₅ or PEDOT:PSS|Ag and between FTO|TiO₂/RGO(2.0 wt%)|P3HT:PC₆₁BM|V₂O₅ or PEDOT:PSS|Ag. Table 2 shows the photovoltaic parameters such as J_{sc} , V_{oc} , FF, PCE, R_s e R_{sh} , calculated from the $J-V$ curves obtained for the best inverted solar cells using TiO₂ and TiO₂/RGO (2.0 wt%) films as ETL and V₂O₅ or PEDOT:PSS as HTL.

According to Table 2, the inverted solar cells based on TiO₂/RGO (2.0 wt%) film, for both configurations, using V₂O₅ or PEDOT:PSS as HTL, showed an increase in J_{sc} , FF e PCE and a decrease in R_s , compared to the devices based on the pure TiO₂ film. The TiO₂/RGO (2.0 wt%) film showed an increase of 18.9% in PCE when using V₂O₅ as HTL and an increase of 33.1% using PEDOT:PSS as HTL. Therefore, independent of the use of V₂O₅ or PEDOT:PSS films as HTL, the incorporation 2.0 wt% of RGO into TiO₂ films had a positive impact, showing that the RGO sheets can introduce an alternative conduction pathway which facilitates the electron transport.

4 Conclusions

In this work, we developed TiO₂/RGO films obtained from a sol-gel method, employing Ti(O^{*i*}Pr)₄ and GO as the starting materials. These films were used as ETL in inverted hybrid

bulk-heterojunction solar cells. In the photovoltaic studies, the influence of different amounts of RGO in the TiO_2 film was investigated and compared to pristine TiO_2 films. The best solar cells based on the TiO_2/RGO films were obtained when the amount of RGO was 2.0 wt%. Devices based on the TiO_2/RGO (2.0 wt%) films exhibited a J_{sc} and PCE of 9.71 mA cm^{-2} and 2.32%, an enhancement of $\sim 22.3\%$ and $\sim 28.9\%$, respectively, when compared with devices based on pristine TiO_2 films. Independent of the use of V_2O_5 or PEDOT:PSS films as HTL, the incorporation 2.0 wt% of RGO into TiO_2 films had a positive impact. The presence of RGO promotes the formation of regions with higher electron collection capacity and reduced Schottky barrier, providing devices with better performances due to more efficient electron transport to the electrodes, as suggested from KPFM images and R_s values. In general, because of its conductive properties, the RGO sheets can act as an electron collector in the TiO_2 film, resulting in an increase in photocurrent and conversion efficiency. However, a dramatic decrease in performance was observed using TiO_2/RGO (4.0 wt%) films due to the increase of R_s , caused by increased resistance toward out-of-plane conduction among RGO sheets and the film darkening, reducing the light absorption of the active layer.

Appendix

The thickness of the TiO_2 and TiO_2/RGO films was estimated through the cross-section of SEM images of all the films, as presented in Fig. 13(a). Figure 13(b) illustrates a graph relating thickness variation versus the concentration of RGO (wt%) for each film.

Figure 13(b) shows that the film's thickness increased significantly from 32.2 to 58.5 nm when the concentration of RGO ranged from zero to 1.0 wt%. In higher RGO concentrations, the thickness did not change much. The TiO_2/RGO (4.0 wt%) film, for example, had a thickness of about 61 nm, which is relatively close to the value measured for the TiO_2/RGO (1.0 wt%) film ($\sim 58.3 \text{ nm}$). The increased thickness of the films may be directly related to increased viscosity of the TiO_2 dispersions due to addition of GO.

Thermogravimetric analysis (Fig. 14) was performed to investigate all the thermal decomposition steps involved for the sample of lyophilized GO. This sample has low thermal stability and is thermally decomposed after three steps. The first mass loss during the initial heating (100°C) refers to the removal of water molecules trapped between the sheets. The second mass loss is observed at about 170°C with a considerable mass loss ($\sim 25\%$) assigned to the pyrolysis of the labile oxygen-containing functional groups. The major mass loss ($\sim 40\%$) occurs in a temperature range from 530°C to 630°C , which was attributed to the combustion of the carbon skeleton of GO.

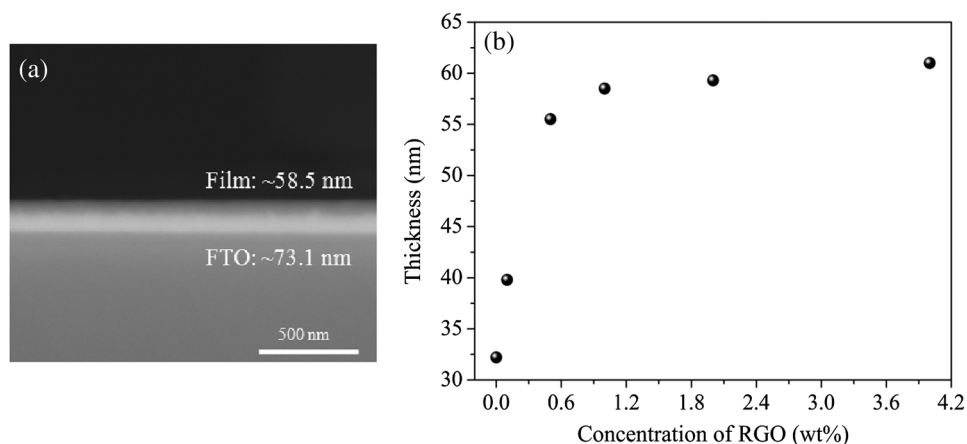


Fig. 13 (a) Cross-section SEM image of the TiO_2/RGO (1.0 wt%) film. (b) Graph of the estimated thickness versus RGO concentration (wt%) for each film.

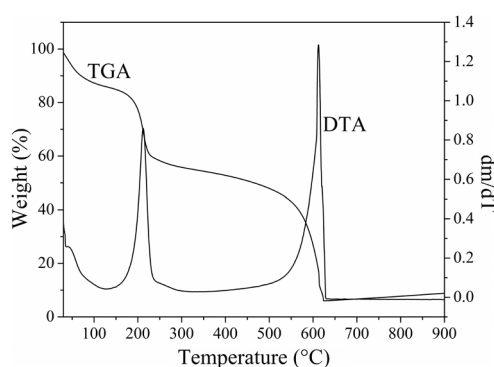


Fig. 14 TGA-DTA curves for the sample of lyophilized graphene oxide in synthetic air.

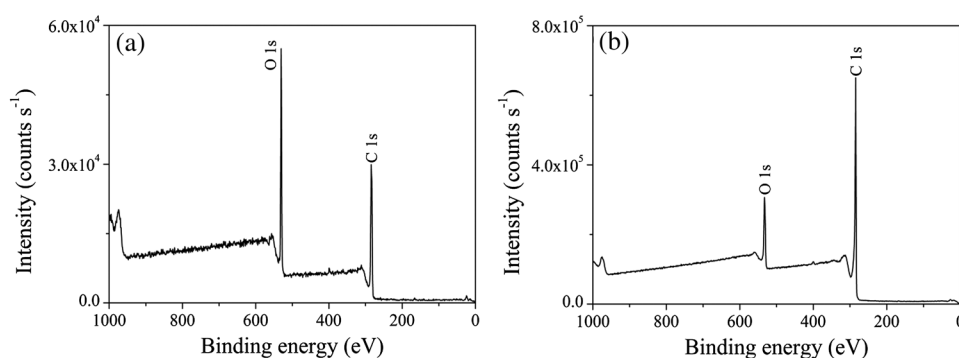


Fig. 15 XPS survey spectra for samples of (a) GO and (b) RGO films, showing the chemical elements in each sample.

XPS survey spectra (up to 1000 eV) were obtained to identify and quantify the elements and chemical groups present in the GO and RGO films, as shown in Fig. 15. The spectra essentially showed the presence of the elements: carbon (C 1s) and oxygen (O 1s) in the region around 284 eV and 532 eV, respectively. Table 3 shows the values of the binding energies, atomic percentage (at %) and the full width at half maximum (FWHM) obtained from each XPS survey spectrum corresponding to the predominant chemical elements carbon and oxygen. According to these data, the C/O ratio was 2.0 for the GO film. This is an indication that functional groups containing oxygen were introduced in the pristine graphite after the oxidation process. For the sample of RGO film, the C/O ratio was 5.8, showing that there was a small increase in this ratio due to partial removal of functional groups containing oxygen after the thermal treatment at 350°C for 1 h.

Table 3 Summary of the XPS binding energies, FWHM (in eV) and atomic percentages for the chemical elements found in GO and RGO films with content higher than 1 at %.

Sample	Element	Binding energy (eV)	FWHM	at %
GO film	C	284.6	2.9	67.0
	O	532.6	4.3	33.0
RGO film (350°C for 1 h)	C	284.6	3.0	85.2
	O	532.6	4.2	14.8

Table 4 Summary of XPS C1s data obtained from fitting calculations regarding the binding energy values, full width at half maximum (FWHM), percentage of each component, and their respective assignments.

Samples	Assignments	Binding energy (eV)	FWHM	at %
GO film	C=C	284.2	1.2	32.1
	C—C	284.9	0.9	13.6
	C—OH	285.5	0.5	3.7
	C—O—C	286.4	1.2	42.4
	C=O	287.7	1.1	5.5
	O—C=O	288.7	1.0	2.2
	$\pi-\pi^*$	289.8	0.5	0.5
RGO film (350°C for 1 h)	C=C	284.2	0.9	53.1
	C—C	284.9	0.9	12.2
	C—OH	285.4	1.6	14.5
	C—O—C	286.1	1.3	9.9
	C=O	287.4	1.9	8.5
	O—C=O	288.7	0.8	1.5
	$\pi-\pi^*$	290.1	0.6	0.3

Table 5 Short circuit current density (J_{sc}) measured using the solar simulator and its theoretical value calculated by integrating the IPCE spectra.

Films	J_{sc} (mA cm ⁻²) measured using the solar simulator	J_{sc} (mA cm ⁻²) theoretical value calculated by integrating the IPCE spectra
TiO ₂	8.05	9.27
TiO ₂ /RGO (0.1 wt%)	9.29	10.01
TiO ₂ /RGO (0.5 wt%)	10.05	11.03
TiO ₂ /RGO (1.0 wt%)	10.29	10.88
TiO ₂ /RGO (2.0 wt%)	9.86	10.75
TiO ₂ /RGO (4.0 wt%)	7.40	8.24

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